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Magnetic anisotropy study of ion-beam synthesized cobalt nanocrystals

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The magnetic properties of Co nanocrystals in crystalline Al_2O_3 and amorphous SiO_2 are investigated. In contrast to the SiO_2 matrix, the Al_2O_3 matrix provides higher magnetic anisotropy and coercive field for Co nanocrystals. Using x-ray photoemission spectroscopy, it is found that a $CoAl_2O_4$ layer forms in Co implanted region. Transmission electron microscopy shows that this $CoAl_2O_4$ layer is grown epitaxially around Co nanocrystals. The higher coercive field of the Co nanocrystals in Al_2O_3 is attributed to the presence of antiferromagnetic $CoAl_2O_4$ layers. © 2006 *American Institute of Physics*. [DOI: 10.1063/1.2364176]

Recently, increasing scientific and technological interests have been placed on the magnetism of nanostructured materials due to their intriguing properties and their potential applications for future ultrahigh density recording media.^{1,2} Previous studies on the magnetism of the nanostructured materials have shown that one of the key challenges is maintaining stable magnetic properties against thermal fluctuations. Ferromagnetic nanosized particles possess reduced magnetic anisotropy and stability, leading to the superparamagnetic state.^{3,4} Magnetic interactions between ferromagnetic nanocrystals and antiferromagnetic coating layers have been exploited to modify the magnetic properties of nanocrystals. The hybrid structure of a Co core and a CoO shell can significantly enhance the magnetic anisotropy and temperature stability of nanostructured Co.^{5,6}

Ion implantation followed by thermal annealing has been utilized to embed various magnetic particles inside a matrix. However, most previous studies used an amorphous matrix or high annealing temperatures providing bigger particles.^{7–9} Hence, the role of the matrix crystal structure or the magnetic stability of ion beam synthesized nanocrystals has been neglected. In the present study, we investigate the effect of matrix structure on the evolution of Co nanocrystals and their magnetic properties using amorphous SiO₂ and single crystalline Al₂O₃ as matrix materials. Our study shows that both Co nanocrystals and CoAl₂O₄ grow with a crystallographic relationship to Al₂O₃ and that the coexistence of these phases increases their magnetic anisotropy.

Crystalline (0001) Al₂O₃ substrates were implanted with 40 keV Co⁺ at a dose of 3×10^{16} /cm². As a companion set, optical grade amorphous silica (*a*-SiO₂) substrates were implanted with the same dose of Co at energy of 25 keV to ensure the same projected range in both substrates.¹⁰ Subsequently, these two sets of samples were annealed at 700 °C in a vacuum of 2×10^{-6} torr. The concentration profiles of implanted ions were monitored by Rutherford backscattering spectrometry.

Magnetic measurements were carried out with a superconducting quantum interference device magnetometer. The magnetic field was parallel to the surface of substrates. Grazing incidence x-ray diffraction (XRD) measurements were made for the as-implanted and annealed samples. The morphology and crystallographic information of Co nanocrystals were analyzed by transmission electron microscopy (TEM; Philips, model CM 30). The oxidation state of Co was analyzed with the aid of x-ray photoemission spectroscopy (XPS; PHI5600 ESCA system). The C 1*s* and Si 2*p* peaks were used to calibrate the binding energy of spectra.

Figure 1 shows the magnetic hysteresis loops M(H) of Co nanocrystals in crystalline Al₂O₃ and amorphous SiO₂, which were annealed at 700 °C. The measurements were performed at 4 K. Clear magnetic hysteresis loops are observed for both samples. The magnetic moment per cobalt atom is $1.25\mu_B$ for the SiO₂ matrix and $1.14\mu_B$ for the Al₂O₃ matrix, which are comparable in both substrates. However, the two samples show a big difference in coercive field, with the Co nanocrystals in the Al₂O₃ matrix being significantly larger; at 10 K, the coercive field of 850 Oe for the Al₂O₃ matrix is two times larger than that for the SiO₂ matrix. The magnetic field corresponding to the saturated magnetization is also higher in Al₂O₃ matrix provides an additional mag-



FIG. 1. In plane magnetization of Co nanocrystals embedded in $\rm Al_2O_3$ and $\rm SiO_2$ at 10 K.

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FIG. 2. Grazing incidence x-ray diffraction patterns of 3×10^{16} Co/cm² implanted Al₂O₃ for as-implanted and 700 °C annealed samples.

netic anisotropy to Co nanocrystals, which increases their magnetic stability.

The higher coercive field of Co nanocrystals in crystalline Al_2O_3 is intriguing. In ferromagnetic nanocrystals, the magnetic anisotropy mainly depends on their size.³ However, the TEM micrographs of two samples (not shown) show similar size of Co nanocrystals in amorphous SiO₂ and crystalline Al₂O₃, indicating that the high magnetic anisotropy of Co nanocrystals inside the crystalline Al₂O₃ is not due to a size effect. Another possible source for high magnetic anisotropy is the surface layer of Co nanocrystals.^{5,6,11,12} The previous studies imply that there may be an antiferromagnetic surface layer on the Co nanocrystals of crystalline Al_2O_3 . Figure 2 shows the grazing incidence XRD patterns of asimplanted and annealed Co in Al₂O₃. Hexagonal closed packed (hcp) Co and Co-containing oxides with a spinel structure are observed in the XRD patterns of the asimplanted sample. In the annealed sample, the intensity of peaks corresponding to hcp structure increases, suggesting the growth of hcp Co nanocrystals during annealing. Also, the peak attributed to (400) Co-spinel points to the presence of a spinel compound, either Co₃O₄ or CoAl₂O₄. XPS measurements confirm the presence of Co spinel and help to distinguish between the Co₃O₄ and CoAl₂O₄ phases. Figure 3 shows the XPS of the Co 2p level in as-implanted and annealed Al₂O₃. While metallic Co is prevalent in the asimplanted state, the XPS data from the annealed samples show a mixture of metallic Co and CoAl2O4. The peak at 781.7 eV and strong satellite at 786.8 eV from the annealed sample indicate that the spinel phase is CoAl₂O₄ instead of Co₃O₄.¹³ It is noted that XPS data of as-implanted samples mainly show metallic Co whereas their XRD data show rather weak signals. This indicates that most of implanted Co ions form very small Co nanocrystals in as-implanted state.¹⁴ When the size of the Co nanocrystals is too small or their crystallinity is low, the characterization tools with different probing scales provide the different signal intensities.

How can a layer of $CoAl_2O_4$ form in the Co implanted region? $CoAl_2O_4$ formation from the reaction of Co and Al_2O_3 is thermodynamically unfavorable at 700 °C, with a positive heat of formation of 62.0 kcal/mol. However, for the case of Co implantation, an excess nonequilibrium concentration of O interstitials can be formed, which can influence the reaction path. Photoemission spectra of O 1*s* for as-implanted and annealed Al_2O_3 in Fig. 3(b) show that the annealing increases the binding energy of O. This change in



FIG. 3. (a) Co 2p core and (b) O 1s core levels of x-ray photoemission spectra (XPS) data of for as-implanted and 700 °C annealed samples.

the binding energy of O proves the presence of O interstitials in the as-implanted Al_2O_3 matrix and their recombination with cations during the annealing process. Therefore, the real reaction that must be considered is between atomic O, metallic Co, and Al_2O_3 matrix and their reaction has a negative heat of formation of -555.7 kcal/mol for Co Al_2O_4 . This indicates that the use of implanted Co and dissociated O interstitial changes the thermodynamic reaction for Co Al_2O_4 from an endothermic to exothermic process and makes the formation of Co Al_2O_4 possible during the ion implantation and subsequent annealing process.

Cross-sectional TEM was performed on Co-implanted and 700 °C annealed Al₂O₃ specimens to investigate their microstructures. Two sets of cross-sectional TEM specimens were examined with different diffraction zone axes, namely, [1010] and [2110]. The TEM results along the [2110] zone axis are presented in Fig. 4. As shown in Fig. 4(a), Co nanocrystals with a size of 3.8 ± 0.8 nm are distributed within the matrix. The size of nanocrystals in TEM images were calibrated by counting the lattice fringes of Al₂O₃ and Co nanocrystals. The spatial resolution of this method was approximately 0.15 nm, which was much smaller than the size of Co nanocrystals. Selected area diffraction patterns, shown in Fig. 4(b), reveal three sets of diffraction spots, indicating the existence of three different materials. The distinctive diffraction spots marked with subscripts A and B represent the diffraction patterns from Al₂O₃ and CoAl₂O₄.^{15⁴} Another set of diffraction spots is indexed to be (0002) hcp Co, lying vertically along the center spot. These observations imply that the $CoAl_2O_4$ layer is epitaxially related to Al_2O_3 and that the Co nanocrystals are strongly textured with the Al_2O_3 and $CoAl_2O_4$. The epitaxial relationship is clearly shown in the magnified diffraction pattern of Fig. 4(b). Three overlaid diffraction spots have the orientation relationship of $\{0006\}Al_2O_3 || \{111\}CoAl_2O_4 || \{0002\}$ Co. The interplanar

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FIG. 4. Cross-sectional high resolution TEM micrographs of 3 $\times10^{16}$ Co/cm² implanted Al₂O₃ for as-implanted and 700 °C annealed samples, (a) HRTEM image showing both unimplanted and implanted regions, (b) diffraction pattern obtained from the same region of (a), (c) HRTEM image of implanted region, and (d) fast Fourier transformation from the same region of (d).

spacing of these atomic planes in bulk crystals are as follows: d (0006) of Al₂O₃=2.165 Å, d (222) of CoAl₂O₄ =2.34 Å, and d (0002) of Co=2.06 Å. The dark spots in high-resolution transmission electron microscopy (HRTEM) micrograph of Fig. 4(c) show Co nanocrystals embedded in a $CoAl_2O_4$ matrix. As shown in Fig. 4(d), the fast Fourier transformation from the same region shows that the orientation relationship between Co and CoAl₂O₄ is the same as that described in Fig. 4(b). This is analogous to previous structural studies showing the lattice match between the (111) plane of $ZnAl_2O_4$ and the (0001) plane of ZnO.^{16,17} The fast Fourier transformation from individual nanocrystals shows the diffraction patterns similar to Fig. 4(d). Since the implanted Co ions form the small Co nanocrystals during the implantation process,¹⁴ this indicates that the preexistent Co nanocrystals provided seeds for the growth of $CoAl_2O_4$ layer.

The peak concentration of implanted Co in Al_2O_3 is 11 at. %. The amount of Co in Co nanocrystals calculated based on the density of nanocrystals observed in Fig. 4(a) is roughly 7 at. %, which indicates that roughly 24 at. % of the Al_2O_3 matrix is expected to convert to $CoAl_2O_4$ after annealing. Given that the percolation threshold is 28 vol % for spherical objects in three dimensions, we conclude that Co nanocrystals are coated by a CoAl₂O₄ layer and that the Co-CoAl₂O₄ hybrid nanocrystals are interconnected three dimensionally in the implanted region of the Al₂O₃ matrix. This distribution picture of each phase (Co, CoAl₂O₄, and Al_2O_3) allows us to understand the increased coercive field and magnetic anisotropy of Co nanocrystals in Al_2O_3 . If the nanostructured ferromagnetic materials are coated by antiferromagnetic layers, the magnetic properties of the antiferromagnetic material may be dominated by interfacial exchange interactions between the ferromagnetic and antiferromagnetic materials, leading to anomalous magnetic behavior.^{5,6,11,12} Since $CoAl_2O_4$ is an antiferromagnetic material,^{18,19} the magnetic interaction between Co nanocrystal and $CoAl_2O_4$ at the interface can change the magnetic properties of Co nanocrystals. The effect of the interfacial exchange interactions is determined by the competition between the Zeeman energy, anisotropy energy, and exchange energy of composites. When the diameter of Co nanocrystals is smaller than 12 nm and the thickness of the antiferromagnetic layer is comparable to it, the Zeeman energy at the interface dominate the anisotropy energy of antiferromagnetic layer.²⁰ Then, the spins in the antiferromagnetic layers rotate under the application of external field and the magnetic anisotropy and coercive field of the system increase, which is observed in this study.

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